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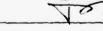
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materials are conductors when oxidized, can be used as electrode materials for the electrochemistry of solution species (eg ferrocene) and are oxidized and reduced at  $\underline{ca}$ . -200 mV vs SCE in  $\mathrm{CH_3CN}$ . The cyclic voltammetry of materials prepared in both  $\mathrm{CH_3CN}$  and in the neutral melt has been investigated in the AlCl<sub>3</sub>:BuPyCl molten salt system and in  $\mathrm{CH_3CN}$ . The most significant differences appear in the kinetics of the redox chemistry. The most facile behavior was observed in a 0.8:1 melt with polypyrrole prepared in the l:l melt.

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TECHNICAL REPORT NO. 16

### ELECTROCHEMICAL POLYMERIZATION OF PYRROLE AND ELECTROCHEMISTRY OF POLYPYRROLE FILMS IN AMBIENT TEMPERATURE MOLTEN SALTS

by

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Prepared for Publication in
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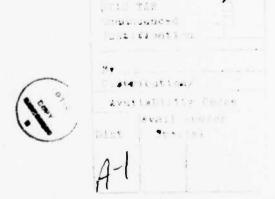
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#### ABSTRACT

Oxidative electrochemical polymerization of pyrrole has been shown to occur in the 1:1 mole ratio AICl3:N-(1-butyl)pyridinium chloride(RuPyCl) molten salt at 40°C. Polypyrrole cannot be prepared in analogous 0.8:1 (basic) or 1.2:1 (acidic) mole ratio melts. The polypyrrole prepared in the molten salt is electrochemically similar to polypyrrole prepared in acetonitrile; both materials are conductors when oxidized, can be used as electrode materials for the electrochemistry of solution species (eg ferrocene) and are oxidized and reduced at <u>ca</u>. -200 mV vs SSCE in CH3CN. The cyclic voltammetry of materials prepared in both CH3CM and in the neutral melt has been investigated in the A1Cl3:RuPyCl molten salt system and in CH3CN. The most significant differences appear in the kinetics of the redox chemistry. The most facile behavior was observed in a 0.8:1 melt with polypyrrole prepared in the 1:1 melt.



Electrodes coated with polymer films have been the subject of considerable interest in recent years (1). An especially important class of polymers in this respect are electronically conducting polymers such as polypyrrole (PP) (2-16). PP coatings have been used as an organic electrode material (7), to protect semiconductor electrodes from photocorrosion (17) as an "ion gate" membrane (18-20) and in electrocatalysis (21). An important potential application of PP is as a charge storing material in rechargeable batteries. However, in CH3CN, in which PP is normally prepared and studied, long term stability and charging rates are problems.

We have recently shown (22) that a number of redox polymers as films on electrodes can be rapidly electrochemically oxidized and reduced in the ambient temperature molten salt system AlCl3/N-(1-butyl)pyridinium chloride (PuPyCl). Since this solvent system is viewed as a promising material for batteries we were interested in using it as a medium for PP electrochemistry.

Mixtures of AlCl3 and RuPyCl in the mole ratios 0.75:1 through 2:1 are ionic liquids at temperatures above  $27^{\circ}$ C (23,24). The dominant equilibrium is (25):

2A1C1<sub>4</sub> + A1<sub>2</sub>C1<sub>7</sub> + C1 logK = -16.9 ± 2 (26)

and the 1:1 melt is almost pure BuPyA1C14 with a considerable amount of ion pairing (27,28). Any A1Cl3 (a Lewis acid) added to the 1:1 melt complexes with A1Cl4 to form A1Cl<sub>7</sub> and the melt is then acidic. When the A1Cl<sub>3</sub>:RuPyCl mole ratio is 2:1 the melt is almost pure RuPyA1<sub>2</sub>Cl<sub>7</sub>. Addition of RuPyCl to the 1:1 melt results in a corresponding increase in free chloride ion (a Lewis base) concentration

and the melt becomes basic. Thus the Lewis hasicity (pfl) of the melt can be varied between 0 and 19. In this work we use the neutral melt (mole ratio=1:1), two basic melts (0.8:1 and 0.95:1) and an acidic melt (1.2:1).

The electrochemical oxidation of pyrrole in acetonitrile produces a polypyrrole film on the electrode (2). When the electrode is transferred to a CH3CN/electrolyte solution the polypyrrole film can be electrochemically driven between the black, highly conducting (100 ohm-1 cm-1) oxidized form and the yellow, non-conducting neutral form. This redox reaction has been characterized as (8):

We have found, and report here, that pyrrole can be electrochemically polymerized in neutral melt (but not in 0.8:1 nor 1.2:1 melts) to form conducting films on electrodes. We also describe the electrochemistry of PP films in pure melts and melts containing electroactive species.

#### EXPERIMENTAL

The preparation and use of the melts used here have been described elsewhere (24). All experiments in melts were performed at  $40^{\circ}$ C in a Vacuum Atmospheres Company dry box under purified argon. Experiments in CH3CN were performed at  $25 + 5^{\circ}$ C.

Flectrochemical experiments were performed using an IRM EC/225

Voltammetric analyzer and a Hewlett Packard 7046A X-Y recorder. A NaCl saturated SCE (SSCE) was used for experiments in CH3CN and an Al wire immersed in 2:1 melt was used as the reference electrode in the melt.

Using ference as an internal reference the Al wire was found to be +110 mV relative to SSCE in CH3CN (The formal potential of ferrocene is +270 mV vs Al in the melt system and +380 mV vs SSCE in CH3CN). Working electrodes were either glassy carbon of geometric area 0.071 cm<sup>2</sup> sealed in Pyrex glass, Pt wire (area = 0.0079 cm<sup>2</sup>) shrouded in Teflon or Pt foil.

Pyrrole was purified on a dry alumina column: Acetoniltrile (Burdick and Jackson; IJV grade) and Et4NC104 (Baker) were used as received.

#### RESULTS AND DISCUSSION

#### Film Growth.

In neutral melt pyrrole (0.17 M) oxidation begins at <u>ca.</u> +0.5V and the peak current occurs at <u>ca.</u> +1.2V at both glassy carbon and Pt electrodes. Polymer films were grown by setting the potential between +0.7V and +0.9V (depending on the required growth rate), switching on the cell, allowing a measured quantity of charge to flow and then switching off the cell. A typical current vs. time profile is shown in Figure 1. After the initial charging current the current falls and then rises to a peak as the film begins to grow. The current then gradually falls as the film gets thicker. The peak time varies from one experiment to the next and the rate of current decrease after the peak is variable but the overall shape of the i vs. t plot is the same for C and Pt electrodes and for different potentials between +0.7V and +0.9V. On Pt, film growth can be verified by inspection: very thin films (<50 nm) are brown and transparent, thicker films are black. On C, film growth is verified by cyclic voltammetry in pure melt.

In 0.8:1 melt (hasic) containing pyrrole (0.17  $\underline{M}$ ) an oxidation wave hegins at +0.5V but attempts to grow PP films from this melt failed. The oxidation current at +0.7V decreased continually with time showing no peak. Failure to grow polymer from this melt is not surprising considering the high C1- concentration ( $\underline{ca}$  . 0.9  $\underline{M}$ ). In the 0.8:1 melt pyrrole oxidation and C1- oxidation occur at about the same potential. Pard and coworkers (13) have shown that oxidation of C1- at PP coated electrodes destroys the polymer. Plaz et al (2) reported that neucleophilic species inhibit PP formation and we have found that LiC1 prevents pyrrole

polymerization in 997 aqueous CH3CN.

In 1.2:1 melt (acidic) only a very small pyrrole ( $0.17 \, \underline{M}$ ) wave was observed at  $\underline{ca}$ . +1.2V. The peak current at C was only 1/40th of that observed in the neutral melt and at Pt the current was down by a factor of over 250. In fact, at Pt the pyrrole oxidation was hardly discernable. No PP films could be grown from the 1.2:1 melt. Presumably pyrrole forms some adduct with A1C13 in the acid melt which cannot be oxidized.

In view of the above results, all films (except those grown in CH3CN) were prepared in neutral melt (the criterion for a neutral A1C:3/BuPyCl melt is that the electrochemical window at C is at least -1V to +2V (29)). PP can be prepared in slightly basic melt (eg 0.99:1) but such films were not used in this work.

#### Cyclic voltammetry of polypyrrole in pure melts.

Polypyrrole coated electrodes, prepared in a neutral melt, were washed with neutral melt and their cyclic voltammetry in a neutral melt and then in a 0.8:1 melt, neither containing dissolved pyrrole, was investigated. Figure 2A shows the first scan (at 100 mV/s) for a ca. 0.2 microns thick (see helow) PP film on C in neutral melt. On subsequent scans the cathodic peak at -0.77V quickly disappeared (after 4 scans) and was replaced by a small cathodic peak at -0.94V which shifted to -0.80V during the next 20 scans. The cathodic peak at -0.36V increased during the first A scans and then decreased. The anodic peak at OV increased during the first 4 scans and then it too decreased. After ca. 20 scans the voltammograms showed little change on subsequent scans and the 20th scan is also shown in Figure 2A.

By comparison with the cyclic voltammetry of PP in CH3CN (8) we interpret the cathodic wave at -0.36 V and the anodic wave at 0V as reduction and oxidation, respectively, of the polymer. The large charging current anodic of this redox couple has been interpreted as indicating that the oxidized form of the polymer is a conductor (13). We have not assigned the cathodic waves in the region -0.7V to -1V but we helieve that they could be associated with the known proton containing species impurity in the melt or with trace oxygen (30).

When the above electrode was transferred to 0.8:1 melt and its potential scanned between -1V and +0.3V at 100 mV/s cathodic and anodic peaks developed at -0.44V and -0.05V respectively (Figure 2R). A small cathodic wave at -0.85V was seen only on the first scan. After all changes in the voltammogram were complete the voltammogram at 5 mV/s shown in Figure 2C was obtained.

We interpret the above behavior and the gradual decrease in the polymer redox waves in neutral melt in terms of the solvent content of the polymer. Oxidation and reduction of the polymer require that anions enter and leave the film or that cations leave and enter the film respectively. These ion movements and hence oxidation and reduction of the film are presumably facilitated by incorporation of the melt into the polymer (solvent swelling) (31,32). Since the polymer was prepared in a melt we can assume that initially it contained some melt. The gradual loss of redox activity in the neutral melt could be due to loss of melt from the film (deswelling) producing a more compact polymer with restricted ion mobility. The return of activity in hasic melt would then he due to chloride ions which, being the smallest ion in the melts, would he expected

to have the highest mobility within the polymer (33) (contrary to bulk melt (34)). This explains the great improvement in the oxidation wave in hasic melt. Oxidation requires movement of anions into a neutral polymer (or cations out of the polymer) and thus is expected to exhibit the greatest kinetic limitations (31). The breakin period observed in the basic melt suggests that more melt is being incorporated into the polymer (22,31,32).

The cyclic voltammetry of PP on Pt electrodes is very similar to that on C electrodes but appears to be more facile. Figure 3 shows voltammograms of a ca. 0.2 micron film of PP on Pt in 0.8:1 melt after potential cycling in the neutral melt and then break-in in the basic melt. The linear dependence of  $i_{pa}$  on scan speed and the average  $i_{pa}/I_{pc}$  of 0.95 indicate that the redox reaction is facile and almost electrochemically reversible under these conditions. The small constant cathodic current between -0.5V and -1V is presumably due to a proton containing species which diffuses through the PP film (33) to the Pt electrode where it is reduced (30).

#### Film thickness and analysis of the cyclic voltammetry of PP.

Estimation of the amount of pyrrole in the PP films and the thickness of the films is not straightforward. For films prepared in CH3CN a number of approaches have been taken. Diaz et al (5,8) measured an n-value of 2.25 for the polymerization reaction and estimated the film thickness from the charge passed during film preparation and the measured density  $(1.5g\ cm^{-3})$  of the film. Their results were supported by measured thicknesses of thick films  $(\underline{ca}, 20\ \text{microns})$  and by the observation that the area under the voltammogram of a PP coated electrode corresponds to 9%

(theoretically 11% if n=2.25) of the charge used to prepare the film. Thus it appears that in CH3CN the polymerization involves 2 electrons per pyrrole molecule and 0.25 electrons per pyrrole unit in the polymer to oxidize the film (as in equation 1).

However, the literature contains other thickness/charge relationships. To produce a 1 micron thick film on a 1 cm<sup>2</sup> electrode the following charges (mf.) are suggested: N.38 (7), 3N (9), 8N 4NN (10), 24N (4,13) and 4NN (8). Presumably the yield of polymer depends upon factors that are not controlled (such as cell design) and so it does not seem advisable to estimate film thicknesses from the charge "sed to prepare the film.

Perhaps the hest way to estimate the quantity of PP in a film is from the area under a slow scan cyclic voltammogram of the film. However, there are two problems. Firstly, the shape of the PP voltammogram (Fig 3), with a small charging current on one side and a large one on the other, makes it difficult to decide what area to measure. Secondly, the charge per pyrrole unit in the polymer is not certain. These two problems are intimately related since the voltammogram merely reflects charging of the polymer film (plus a small constant charging current for the underlying electrode). There seems to be the misconception in the literature that the anodic and cathodic waves at  $\underline{ca}$ . -0.2V correspond to the redox reaction of the polymer and the large currents anodic of these waves are "background" and should be ignored. Any current in the voltammogram that cannot be attributed to the underlying electrode nor to dissolved redox species must be due to charging and hence formal oxidation or reduction of the polymer film.

One would not expect PP to exhibit a typical redox polymer surface

wave (35-39) since presumably it consists of chains or conjugated segments of chains with a range of lengths and hence with different formal potentials (6,16). (A conjugated segment is a section of a chain that is electronically isolated from the rest of the chain by a bend, twist or defect.) It is not reasonable to assume that PP consists of non-interacting or only weakly interacting redox sites with one formal potential. The inverse relationship between chain length and anodic peak potential found for pyrrole oligomers (Epa,N = 1.35/N-0.15 (6,16)) gives some indication of the distribution of  $F^{O_1}$  values for the segments of polymer. There is some evidence (6) that these segments are predominantly short, possibly only 5-10 pyrrole units long.

The problem of multiple oxidations and reductions of these segments makes theoretical simulations of this model difficult but intuitively it is compatible with the observed cyclic voltammetry. The peaks in the voltammogram correspond to oxidation and reduction of the longer segments whose formal potentials are bunched together by the 1/N relationship; the large "charging current" anodic of the peaks corresponds to primary redox reactions of the shorter segments and secondary and higher order redox reactions of the longer segments. Thus the average charge per pyrrole unit must be potential dependent at all potentials anodic of -0.5V.

The alternate and previously assumed explanation for the "charging currents" anodic of the main redox waves is that the oxidized form of PP is similar to a porous metal and that these currents are double-layer charging currents of the PP. This model has been investigated by Bard and co-workers (13) and theoretically formulated by Feldberg (15).

The relative valitity of these two models depends upon the microscopic

structure of the PP when immersed in and swollen by the solvent. If the swollen PP consists of chains of PP which are each in contact with solvent, then the former model is the more appropriate. However, if the PP chains are arranged in fibres of diameter large relative to the size of a pyrrole molecule, which are impervious to the solvent then the porous metal model is more reasonable (15).

At this stage we cannot say which model hest describes PP in the molten salts used in this work. However, the hreak-in hehavior observed in the basic melt, the sensitivity of the PP electrochemistry to chloride ion concentration and the differences hetween PP prepared in a melt and PP prepared in CH3CN (see helow) suggest that in the melts PP is non-rigid and contains pores of molecular dimensions (31-33). We feel that this behavior is more compatible with the solvated redox polymer model than with the porous metal model.

The average charge per pyrrole unit in oxdized PP has been estimated a number of times (5,8,10-12). The films were removed from the preparation solution while at the preparation potential ( <u>ca.</u> +0.8V vs SSCE), washed, dried and analyzed. The analyses correspond to one anion per 3 or 4 pyrrole units depending upon the anion. To estimate the number of pyrrole units in a PP film one should thus measure the charge under the voltammogram and divide hy 3 or 4. However, the measured charge should include the "background" or "charging current" (except that due to the underlying electrode) up to the preparation potential ( <u>ca.</u> +0.8V) since this additional charge also must lead to incorporation of anions into the film. This last conclusion is <u>independent of the model</u> used to describe the charging of the polymer film.

Diaz et al (8) indicate that they measured only the charge under the anodic peak and could not "account properly for the change in background current". Accordingly the measured charge (9% of preparation charge) corresponds to less than the expected 11% of the charge used to prepare the film. However, it is clear from the published voltammogram that if the anodic current is extrapolated to the preparation potential (+0.81V) the measured charge ( ca. 16% of preparation charge) corresponds to significantly more than expected. Analysis of our results for PP in melts yields ca. 16% for Ocy/Oprep (where Ocy is the average of anodic and cathodic charges under the cyclic voltammngram). This indicates that either more than one pyrrole unit in four is oxidized at Forep or that less than 2 electrons per molecule are required for the polymerization. The latter is certainly likely since there must be end units which only need one electron. However, if this were the sole explanation, the average chain length would have to be three, which is unreasonable. Thus this analysis suggests that at +0.81V in CH3CN and at +0.70V in the melt more than one pyrrole unit in four is oxidized.

The above discussion indicates that no reliable way of quantifying PP films has been found. For films prepared in molten RuPyAlCl4 the problem is even greater because the films cannot be washed and dried with any confidence that the final product will be representative of the initially prepared film. From inspection of the voltammograms of Figures 2 and 3 it is clear that the charge under the voltammogram cannot accurately be measured as described above. It seems therefore that the hest approach is to use the charge used to prepare the film as a relative measure of the quantity of film produced. As a rough conversion to film thickness we

assume that 240 mC/cm<sup>2</sup> yields a film 1 micron thick (4,13). We do this merely to allow some comparison with the literature on PP in CH<sub>3</sub>CN.

#### Formal potential.

The discussion in the preceeding section implies that PP does not have a unique  $E^{\text{O}}$ . It is made up of many segments with different and multiple formal potentials.

In CH3CN the "E0" of PP has been measured as the midpoint between  $E_{Pa}$  and  $E_{Pc}$  and found to be  $-22\Omega mV$  vs SSCE (8) which translates to -330~mV vs the melt refrence system (assuming ferrocene/ferrocenium has the same formal potential in both solvent systems). Using this method for PP in melts we obtain the apparent formal potentials  $(F_{app}^{O_1})$  shown in Table I. These show that in the melt the PP is oxidized and reduced at a potential slightly more positive than in CH3CN and that there appears to be a slight dependence on melt basicity. The nature of the PP electrochemistry and the variable kinetics which influence the peak positions make  $E_{app}^{O_1}$  a poor parameter from which to draw more complete conclusions.

#### Cyclic voltammetry in hasic melt of PP films prepared in CH<sub>2</sub>CN.

PP films on C and Pt electrodes were prepared at  $\pm 0.75 \text{V}$  vs SSCF from 99% aqueous CH3CN containing Et4NClO4 (0.1 M) and pyrrole (0.1 M). Figure 4A shows voltammograms in 0.8:1 melt and 0.1 M Ft4NClO4/CH3CN of a Pt electrode coated with PP using 14 mC/cm² of charge. The potential axes have been aligned so that ferrocene would have the same FO' in both solvents. The voltammogram in the melt was recorded first, then after washing the electrode well with CH3CN the voltammogram in

CH3CN was recorded. The charge used to prepare this film is a third of that  $(42 \text{ mC/cm}^2)$  used to prepare the film of Figure 3. It can be seen that the PP film made in CH3CN does not function well in the melt, even after cycling (over 30 scans between -1V and +0.3V). Even in CH3CN the voltammogram is not as sharp and symmetrical as that of the thicker film prepared and used in the melt (Figure 3). Thus PP films prepared and used in the melt exhibit more facile electrochemistry than those made in CH3CN. This is especially noticeable and important for reduction of the film which is a problem in CH3CN (8). The same conclusions result from experiments with PP on C electrodes.

#### Cyclic voltammetry in CH3CN of PP films prepared in neutral melt.

Figure 4R shows cyclic voltammograms in 0.8:1 melt and in CH3CN/Et4NCl04(0.1  $\underline{\text{M}}$ ) of a Pt/PP (0.2 microns) electrode which was prepared in a neutral melt. The potential axes have been aligned so that ferrocene would have the same E0' in both solvents. The film was washed with toluene between preparation and use in 0.8:1 melt; it was then washed with toluene, acetonitrile and water and dried in air before use in CH3CN.

The voltammogram of the PP film in the melt has more pronounced peaks than the voltammogram of the same film in CH3CN. We take this as indicating that the redox chemistry of the film is more facile in the melt than in CH3CN although the difference could possibly he due to thermodynamic factors. The differences in peak positions in Figure 4R is not regarded as significant given the variability of  $F_{app}^{O_1}$  (see tables 1 and 2).

#### Ferrocene electrochemistry at PP coated electrodes.

PP in its oxidised form represents a new class of electrode materials (7,8). Conducting organic materials are potentially useful electrode materials for organic electrochemistry. Another potential application of PP coatings is the modification of the electrochemical properties of inexpensive electrode materials such as nickel (4N) so that such electrodes are useful for both analytical and synthetic electrochemistry. We have therefore investigated the electrochemistry of ferrocene at PP coated alectrodes in hasic and acidic melts.

Figure 5 shows the cyclic voltammetry of 130m M ferrocene in 0.8:1 melt at naked Pt and at Pt/PP (0.25 and 1.0 micron) electrodes. There is a large "charging current" in the region of the FeJII/II couple at the PP coated electrodes but the ferrocene wave is virtually unaffected. To decide whether the results of Figure 5 clearly show that the ferrocene reactions occur predominantly at the film-solution interface requires a comparison between the film thickness (d), the thickness of the diffusion layer ( $\delta$ ), the diffusion coefficient of ferrocene in the hulk solution (0.5) and in the polymer film (0.5) and the partition coefficient of ferrocene from the solution to the film (0.5). Here the film non-conducting, the ferrocene electrochemistry would only be insensitive to the presence of the polymer if (0.5):

 $n_pP/d \gg n_s/\delta$  (2) In the present case  $n_s = 4.8 \times 10^{-7} \text{ cm}^2 \text{ s}^{-1}$  (42),  $\delta \sim 10^{-3} \text{ cm}$  (estimated from  $(2n_st)^{1/2}$  with t = 1s) and  $d = 2.5 \times 10^{-5} \text{ cm}$  for the thinner film of Figure 5. Therefore,  $n_pP$  would have to be greater than

1.2 x 10-8 cm² s-1 for the film to have no effect. This seems unreasonably high since there is no reason to expect that P is much greater than 1 and we have presented evidence that the mobility of the melt ions and hence presumably ferrocene is low in the polymer. Thus, we take the lack of a significant difference in the ferrocene wave at the three electrodes as indicating firstly that the PP films are conducting and have negligible resistance compared to the solution resistance and secondly that ferrocene electrochemistry takes place rapidly and reversibly at the PP/solvent interface. These results are consistant with the results obtained by other workers using CH3CN(8,13).

In an acidic melt (1.2:1) the PP redox wave ( $E^{O_1} = -0.2V$ ) cannot be seen because the cathodic limit of the melt is <u>ca</u> .=0.3V. However, ferrocene ( $F^{O_1} = 0.27V$ ) electrochemistry in a 1.2:1 melt at a Pt/PP (0.17 microns) electrode is almost identical to that at naked Pt for the first few scans between 0 and +1V. On subsequent scans the wave broadens and the peak currents decrease.

These results show that PP may be a useful electrode material in ambient temperature molten salts. When oxidized it has excellent conductivity and its charge transfer rate to ferrocene in solution is fast in both acidic and basic melts. The origin of the stability problem in the acidic melt has not been determined.

#### Conductivity.

The cyclic voltammetry of PP prepared in the neutral melt suggests that the polymer is conducting when oxidized and non-conducting when

reduced. These conclusions are supported by the fact that ferrocene electrochemistry ( $E^{O_f} = 0.27V$ ) can be observed at the PP/melt interface but HCl electrochemistry ( $E^{O_f} \sim -0.5~V$  in 0.8:1 melt) cannot. HCl (from H2D) is an impurity in all the melts used in this work and exhibits a quasi reversible redox wave at Pt electrodes. At thin film Pt/PP electrodes some reduction of HCl at Pt is observed as a membrane diffusion wave but there is no evidence for reduction at the PP/melt interface. There are two possible explanations for the inability of the PP film to reduce HCl. Fither the reduced form of the polymer is non-conducting or the kinetics of HCl reduction on PP are very slow.

In order to estimate the conductivity of the PP prepared in the neutral melt a thick film of PP (ca. 20 microns) was grown on a Pt flag. The film was removed from the melt while still potentiostated at 0.85 V, washed with CH3CN and water and dried in air. During this process the film noticeably shrank and peeled from the electrode. The resistance of the film was measured between two clips separated by ca. 2 cm. A rough estimate of the conductivity was  $10^{-1}$  cm<sup>-1</sup>.

#### Summary of cyclic voltammetry of PP and conclusions.

Table 2 lists cyclic voltammetric data for a number of Pt/PP and C/PP electrodes in various melts and in CH3CM. The term  $\Delta$ ip/Oprep $\nu$  (where  $\Delta$ ip is the difference between the peak anodic and cathodic currents and Oprep is the charge used to prepare the film) should be constant and any variation should reflect kinetic limitations.

A number of important conclusions can be drawn from Table 2.

(a) For films thicker than 100 nm the kinetics of oxidation and

reduction influence the voltammetry at scan speeds as low as 20 mV/s. This appears as an increasing  $\Delta F_p$  and a decreasing  $\Delta i_p/\Omega_{prep} v$  with increasing scan speed or increasing film thickness.

- (b) The 100 nm film on Pt appears to show no kinetic limitations up to 200 mV/s since  $\Delta E_p$  is effectively constant. However, there is a residual  $\Delta E_p$  which is presumably thermodynamic in origin (6). This thermodynamic  $\Delta E_p$  must be lower in a 0.8:1 melt than in a 0.95:1 melt.
- (c) PP electrochemistry is much more facile on Pt than on glassy carbon. This conclusion is also supported by other data not included in Table 2.
- (d) The anodic wave is more susceptible to kinetic limitations than is the cathodic wave. Thus, as the scan speed or the film thickness is increased and  $\Delta E_p$  increases,  $E_p$  changes more than  $E_p$  and so  $F_{app}$  moves to more anodic potentials.
- (e) Films prepared in a neutral melt exhibit more facile electrochemistry in a N.8:1 melt than in CH3CN.
- (f) Films prepared in CH3CN show very poor electrochemistry in a 0.8:1 melt when compared to similar films prepared in the neutral melt. In CH3CN they are similar to films prepared in the neutral melt.
- (g) Peak positions are poorly reproducible. This is probably due to different degress of swelling and hence variable kinetics and thermodynamics.

It should be noted that the differences between CH3CN and the melt may be in part due to the different termperatures employed for experiments in the two solvents.

#### CONCLUSIONS

Polypyrrole films can be prepared in molten RuPyAlCl4 and the electrochemistry of such films in 0.8:1 mole ratio AlCl3:RuPyCl melt appears to be more facile than that of PP films prepared in CH3CN. The films prepared in the melt are conducting when oxidized and are potentially useful electrode materials. Their charge storing properties are superior to those of previously described PP films.

Further work concerning the nature of the electrochemical reaction of PP and the conductivity of films prepared in molten salts is in progress.

#### CREDIT

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Table 1. Apparent formal potentials for PP in neutral and basic melts  $\epsilon_0$  , mv vs. Al/Al(III) in 2:1 melt.

in 1:1 melt in 0.80:1 melt	-150	-240	-250	-280	-230
in 1:1 melt	no anodic	-160	-240	-200	-200
Approx. film thickness, nm.	20	200	8	170	and and a
Substrate	U	U	£	ħ	

TABLE 2. Cyclic Voltammetric Data For Polypyrrole Films (all potentials vs. Al/Al(III) in 2:1 melt).

Substrate Qprep,mC	Qprep,mC/cm²	Approx. film thickness,nm.	Melt or Solvent	Scan rate,mV/s	Epa,mV	Epc,mV	Eapp ,mV	Eapp, mV dEp, mV	Atp/aprep
£	<b>5</b> 2	100	0.95:1	40 200 400 400	-220 -220 -200 -200	-330 -330 -350	-280 -290 -260 -270	130 140 130	0.51 0.48 0.48
<b>z</b> ,	42	170	0.80:1	2000000 200000000000000000000000000000	-240 -220 -230 -130 -130	-320 -340 -360 -380 -400	-280 -280 -280 -280 -280	110 110 170 210 270	0.66 0.60 0.56 0.53 0.53
o	84	500	0.80:1	200000 200000	-150 -130 - 80 - 40 +180 +350	-330 -380 -420 -450 -590	-240 -250 -250 -250 -250 -170	180 250 340 410 770 1040	0.52 0.47 0.35 0.30
£ 0	239	31	0.80:1 0.80:1 043CA	10 100 100	- 90 -170 -250	-340 -330 -350	-220 -300	250 160 100	0.44 0.29
£	14	200	0.80:1 0.80:1	86 61	-230 -140 - 10 - 260	-350 -360 -310 -310	-250 -250 -160 -310	22 22 20 100 100	0.45 0.32 0.15 0.31
£ .	95	506	0.80:1 CH <sub>3</sub> CN	100	- 30	-340 -390	-210	250	0.00

(a) PP prepared in CH<sub>3</sub>CN (b) Potentials adjusted to melt reference system by comparison with ferrocene.

#### FIGURE LEGENDS

- Figure 1. Current vs. time profile for pyrrole polymerization at +0.7V (vs. Al/Al(III) in 2:1 AlCl3:RuPyCl melt) onto a glassy carbon electrode from 0.17 M pyrrole in neutral AlCl3:RuPyCl melt.
- Figure 2. Cyclic voltammetry of a C/polypyrrole (0.2 micron) electrode in neutral (A) and hasic (0.8:1; B and C) AlCl3:RuPyCl melts.

  Scan speed = 100 mV/s for A and B, 5 mV/s for C.
- Figure 3. Cyclic voltammetry as a function of scan speed for a Pt/polypyrrole (0.2 micron) electrode in 0.8:1 AlCl3:RuPyCl melt.
- Figure 4. Cyclic voltammetry of Pt/polypyrrole electrodes in N.R:1

  AlCl3:BuPyCl melt (---) and in N.1 M Et4NClN4/CH3CN

  (---). A, N.N6 micron PP film prepared in CH3CN. B, 0.20

  micron film prepared in neutral melt. Scan speed = 100 mV/s.
- Figure 5. Cyclic voltammetry of 130 m M. ferrocene in 0.8:1 AlCl3:RuPyCl melt at naked Pt (----) and at Pt/polypyrrnle (0.25 micron. ---- and 1.0 micron ——) electrodes. Scan speed = 100 mV/s.

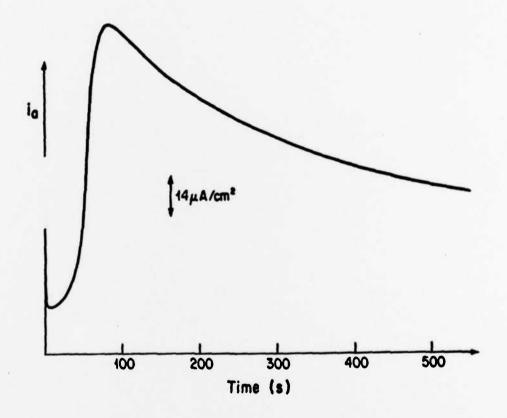


FIGURE 1

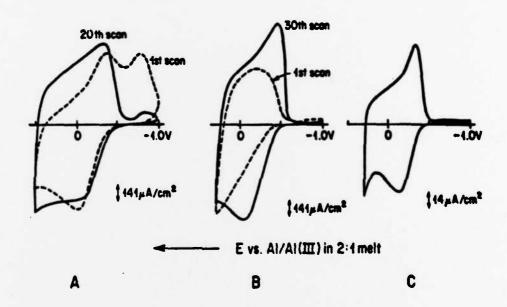


FIGURE 2

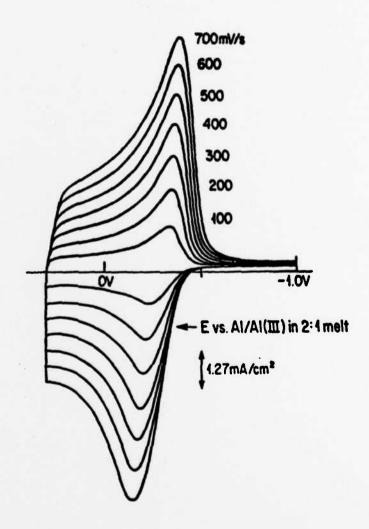


FIGURE 3

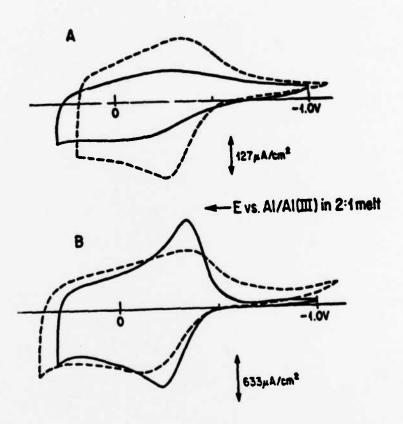


FIGURE 4

-1.0V
-1.0V
-1.0V
-1.0V
-1.27 mA/cm²

FIGURE 5

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